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Directed self-assembly (DSA) of block copolymers: a platform for nanomanufacturing

Here we will present the thermodynamic and

kinetic analysis of the DSA processes we developed that are being implemented in manufacturing relevant settings at IMEC and at HGST, a Western Digital Company. The discussion will focus on the potential for those processes to meet the constraints for semiconducting manufacturing and fabrication of nanoimprint templates for bit patterned media.

Thursday,
May 1st
10 AM GCIS W301

http://ime.uchicago.edu/